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Form PTO-1449 (REV. 8-83)							APPLICATION NO. 10/076,302			
INFO	RMATI	ION DISCLOSURE STATEMENT		ļ						
O / P (Use several sheets if necessary)			APPLICANTS Yoshihito NARITA et al.							
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Aulab	1	JP A 2000-215499 (w/abstract)	08/	04/2000	Japan					
	2	JP A 2000-132856 (w/abstract)	05/	12/2000	Japan					
+	3	JP A 2000-223767 (w/abstract)	08/	11/2000	Japan					
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Lee et al., "Nanometric aperture arrays fabricated by wet and dry etching of silicon for near-field optical storage application", J. Vac. Sci. Technol. B, Vol. 17, Number 6, pages 2462-2466, Nov/Dec 1999										
1	6	Yatsui et al., "High-density-speed optical near-field recording-reading with a pyramidal silicon probe on a contact slider", OPTICS LETTERS, Vol. 25, No. 17, pages 1279-1281, September 2000								
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